

Recent Results on NEG Coating Characterisation

Ruta Sirvinskaite

Oleg B. Malyshev, Reza Valizadeh, Adrian Hannah, Michael D. Cropper









ASTeC

Outline

- NEG coating and its propeties 1.
- Tested samples and their morphology 2.
- 3. NEG characterisation system
- 4. Experimental procedure
- Sticking probability at room temperature 5.
- Cooling a non-activated sample 6.
- ESD at room temperature before and after activation 7.
- 8. ESD during cooling
- Sticking probability at cryogenic temperatures 9.
- 10. ESD at 90 K
- 11. Conclusions and future experiments



NEG Coating

One of two surface treatments considered in EuroCirCol WP 4 Task 4 to mitigate e-cloud and ion instabilities



Ultimately, the deflector design was proposed



NEG as candidate material

Advantages:

- **Distributed pumping** no pumping holes needed, beam and insulation vacuum can be separated
- Reduced electron-, photon- and ion-stimulated desorption (ESD, PSD and ISD) yields
- Secondary Electron Yield SEY < 1
- SR activation @ RT avoid heating of the tube (challenging at any temperature)

Main question:

Can these properties be kept at cryogenic temperatures?







Parameter	Dense	Columnar
Gas	Kr	Kr
Pressure	10 ⁻³ mbar	0.1 mbar
Power supply	Pulsed DC	DC
Temperature	90-110 °C	90-110 °C

Two tubular samples

- TiZrV coating deposited from • alloy wire
- Tube length 50 cm ٠
- Tube diameter 3.8 cm •
- Columnar structure •



Sample morphology



STEC NEG vacuum properties evaluation at cryogenic temperatures





ASTeC



ASTeC activation procedure



To re-activate the NEG, sample has to be heated again



ASTe(

Sticking probabilities at room temperature

Vacuum chamber modelled in Molflow, the data used to convert pressure ratio to sticking probability of NEG coating

Activations to 120, 140, 150, 160, 180, 200, 220, 250 and 300 °C – pressure ratios recorded



CO nearly fully pumped after activation to 180 °C





Sample	Description of the experiment	Pump	Activation	Cooling	Result
1	H ₂ &CO injections	None	120-190	No	α vs T _{activation}
2	ESD	TMP	None	Yes	Activation with ESD?
2	Desorption from hot filament	ТМР	None	Yes	Cryosorption
2	ESD	TMP	180	No	η @ RT
2	ESD	ТМР	180	Yes	η and η' @ CT
2	H ₂ +CO injections	SIP	180	No	α @ RT
2	Desorption from hot filament	ТМР	180	Yes	α(Τ)
2	Ar, CO ₂ , CO, CH ₄ , H ₂ injections	ТМР	None	Yes	Cryosorption of diferent gases
2	ESD	TMP/N	None	Yes	Activation with ESD?
2	ESD	TMP/N	180	Yes	η and η' @ CT
2	H ₂ &CO injections	ТМР	180	Yes	α(Τ)

ASTeC



Experimental procedure for cryogenic measurements



Sample was activated to 180 °C again after these experiments



Cooling a non-activated sample

Pressure inside the NEGcoated chamber during cryogenic ESD experiments Gas density inside the NEGcoated chamber as a function of temperature during ESD

$$n_t = n_{RGA} \frac{v_{RT}}{\overline{v_t}} = \frac{P_{RGA}}{k_B \sqrt{T_{RT} T_t}}$$





ASTEC Initial ESD yields before and after NEG activation

Comparison of initial ESD yields (molecule/electron) before and after NEG activation

Gas	Before activation	After activation
H ₂	0.2	0.01
CH ₄	6×10 ⁻³	2×10 ⁻³
CO	0.025	5×10 ⁻³
Ar	2×10 ⁻⁴	2×10 ⁻⁶
CO ₂	6×10 ⁻³	1.5×10 ⁻³

ESD yield after NEG activation as a function of dose





ASTeC ESD from activated NEG coating at cryogenic temperatures

Pressure inside the NEGcoated chamber during cryogenic experiments Gas density inside the NEGcoated chamber as a function of temperature



Sticking probability measurements at cryogenic temperatures

1. The source of gas – hot filaments placed along the test tube

$$\alpha_{CT} = \alpha_{RT} \frac{P_{RT}}{P_{CT}}$$

2.12 hours activation, then gas injection + TPMC



0.1

Ruta Sirvinskaite, FCC Week 2019, Brussels

5×10⁻²

CO

ASTeC Gas density inside the NEG-coated chamber during cooling down



ASTe(



ESD yields were calculated using data for sticking probabilities and measured gas density; however, ESD yield cannot increase at low temperature

Hyperbolic Solution BT 0.1 × 0.01 1×10^{-3} $\times \times \times H2$ + + + CC 1×10 100 200 300 400 T [K]

Ruta Sirvinskaite, FCC Week 2019, Brussels

yield [molecules per electron]









H₂ ESD and PSD

H2 pressure increase during photo desorption measurements from copper.

ESD at 85 K (2019)

PSD at 4.2 K (V. Anashin et al., 1994)





ASTeC



ESD at 85 K - gas density



Ruta Sirvinskaite, FCC Week 2019, Brussels



Conclusions and future experiments

Task	Problem	Solutions
ESD and pumping	Does NEG coating work at cryogenic temperatures?	 For CO: η reduces and α increases For H₂: η and α - small change, η' effect (like at 4.2 K) is observed on activated NEG surface
NEG activation with SR	Would SR induced activation of NEG coating be possible at cryogenic temperatures (like it is observed at RT)?	No such effect observed at cryogenic temperature
New types of NEG coatings	Different composition, morphologies	 Columnar and dence films of Ti-Zr-Hf-V, Ti-Zr-V and Zr films have been studied



ASTeC

Acknowledgements

- The European Circular Energy-Frontier Collider Study (EuroCirCol) project has received funding from the European Union's Horizon 2020 research and innovation programme under grant No 654305. The information herein only reflects the views of its authors and the European Commission is not responsible for any use that may be made of the information.
- The target was funded by the National Key Research and Development Program of China under grant No 2016YFA0402004.
 - Many thanks to the EuroCircol WP4 participants and staff at Daresbury laboratory, most importantly Adrian Hannah and James Conlon